



DOCKET NO: 218781US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :  
TAKEYOSHI SHIBASAKI, ET AL. : EXAMINER: NGUYEN, NGOC YEN M.  
SERIAL NO: 10/049,902 :  
FILED: JULY 8, 2002 : GROUP ART UNIT: 1754  
FOR: AMORPHOUS FINE SILICA :  
PARTICLE, ITS PRODUCTION PROCESS  
AND APPLICATION

AMENDMENT AND REQUEST FOR RECONSIDERATION

COMMISSIONER FOR PATENTS  
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Office Action dated July 28, 2005, please amend the above-identified application as follows:

**Amendments to the Claims** begin on page 2 of this paper.

**Discussion of Amendment** begins on page 6 of this paper.

**Remarks** begin on page 7 of this paper.